

Shear Strain-Induced Multiferroic Response in the Altermagnetic Semiconductor CuFeS_2

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CuFeS_2 is an altermagnetic semiconductor that is lattice-matched with silicon and has a high Néel temperature. It is nonpolar and magnetically compensated in its structural ground state. However, the crystal belongs to a magnetic symmetry class allowing simultaneous piezoelectricity and -magnetism, indicating that distortion by shear strain may enable functional properties not observed in its tetragonal ground state. This first-principles study explores how biaxial and shear strain affect the crystal structure and functional properties. Biaxial strain lowers crystal symmetry when applied to two of the three crystallographic $\{001\}$ planes considered, enhancing the altermagnetic lifting of the Kramers degeneracy. Shear strain has a compressive effect on the crystal, enhancing the effects on the electronic structure seen under biaxial compressive strain. Applying it to any one of the three $\{001\}$ planes induces a polar phase with an out-of-plane electric polarization, perpendicular to the strained plane. Moreover, applying shear strain to two out of the three $\{001\}$ planes induces a net magnetization simultaneously with electric polarization, producing a multiferroic response.

I. INTRODUCTION

Research on devices utilizing spin currents to increase the efficiency of electronics requires technologies that allow exerting control on the injection and polarization of spin currents. Ferromagnetic semiconductors show potential in spintronic applications. However, attaining Curie temperatures at room temperature levels remains a challenge. Furthermore, their external fields cause magnetic interference with other components when densely packed¹⁻⁴. Antiferromagnets enable operating frequencies on the order of THz and do not interfere with other components, attracting research interest as candidate materials in spintronic components⁵⁻⁷. Exerting control on antiferromagnetic spin structures, however, is challenging. Promising results have been demonstrated, e.g., in systems exhibiting spin-orbit coupling (SOC) and a non-collinear antiferromagnetic order via the spin Hall effect⁸⁻¹¹. Altermagnets combine a compensated magnetic structure with the lifting of Kramer's degeneracy and spin-polarized bands, features thought to be mutually exclusive. Moreover, they demonstrate momentum-dependent spin band splitting, allowing the generation of spin currents¹²⁻¹⁵. Recently, altermagnets with multiferroic properties have received much interest for their potential to control the spin degree of freedom with electric fields. However, the previously proposed material candidates are not altermagnetic at room temperature or have not yet been synthesized¹⁶⁻¹⁸. Here, we consider a recently synthesized altermagnetic candidate that allows for electrical polarization induced by strain, with a Néel temperature significantly above room temperature.

Chalcopyrite, CuFeS_2 , is a magnetic semiconductor with

a collinear compensated magnetic order up to a Néel temperature¹⁹ of 823 K and has long been studied for its thermoelectric properties²⁰⁻²⁵. Its bulk tetragonal crystal structure belongs to space group²⁶ no. 122, $I\bar{4}2d$, and can be viewed as a stack of two zincblende unit cells, with the corner and face center cations alternating between the zincblende unit cells. Figure 1 illustrates how each cation is coordinated in a corner-sharing tetrahedral environment, consisting of four S anions. The magnetic structure, indicated in Figure 1 using red arrows, is analogous to A type antiferromagnetism in cubic structures, exhibiting intraplanar ferromagnetic and interplanar compensated antiferromagnetic coupling.

Recently, progress was made synthesizing CuFeS_2 thin film using molecular beam epitaxy²⁷. With the in-plane lattice parameter of CuFeS_2 , 5.24 Å, being similar to that of silicon, 5.43 Å^{28,29}, chalcopyrite is potentially compatible with existing semiconductor technology. Moreover, CuFeS_2 exhibits spin-polarized electron bands located at the conduction band minima. This spin-polarization is a signature of the magnetic symmetry class of CuFeS_2 . The absence of joint inversion and time reversal, and joint time reversal and translation symmetries, distinguishes CuFeS_2 from conventional collinear antiferromagnets. Its magnetic sublattices are related by rotations, such that it classifies as an altermagnet³⁰. Altermagnets have received the majority of the attention for their spin-polarized bands^{4,14,31}.

The magnetic class of CuFeS_2 allows for other properties, such as non-trivial responses to strain engineering³²⁻³⁴. Epitaxial strain from small lattice mismatches, changes in stoichiometry or inhomogeneous thermal expansion between substrate and thin film has been studied extensively in numerous materials for its ability to induce new properties. Strain-

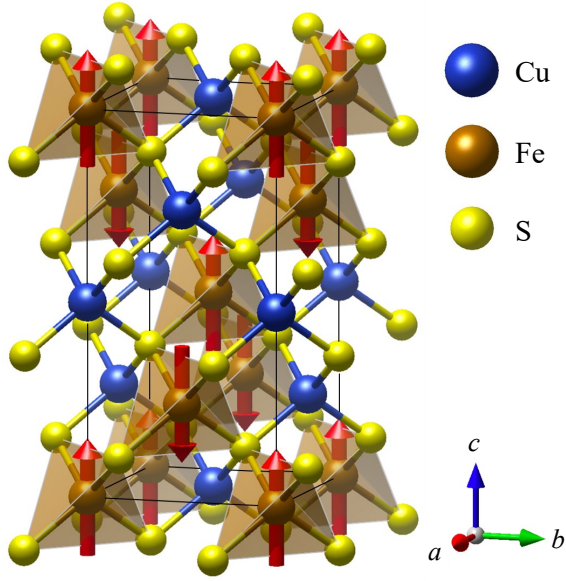


FIG. 1. Tetragonal structure of bulk CuFeS_2 . The ground state magnetically compensated spin structure is indicated by red arrows.

engineering has been applied to, e.g., enhance carrier mobility in Si, reduce effective carrier mass in III-V semiconductors or alter bandgaps^{35,36}. Extensive research on applying strain in magnetic materials and insulators, such as oxide perovskites, revealed metal-insulator transitions^{37,38}, transitions between ferromagnetic and antiferromagnetic order^{39–42}, tunability of giant magnetoresistance⁴³ and spontaneous polarization and ferroelectricity^{44–46}.

Yet, the physical response of CuFeS_2 to applied strain is unexplored. In this density functional theory (DFT) study, the elastic, magnetic, and electronic responses of CuFeS_2 to applied strain is considered. The bulk structure is strained (i) biquadratically and (ii) by shearing along the $\{001\}$ planes. Biaxial strain applied to the (001) plane spanned by the a and b lattice vectors, ab , preserves the tetragonal symmetry, whereas applied to the ac or bc plane, it induces a phase transition to orthorhombic $I2_12_12_1$ structure. Shear strain applied to the ab plane results in the orthorhombic phase $Fdd2$, which is piezoelectric. Applying shear strain to the ac or bc plane gives a monoclinic phase, $C2$, which is both piezoelectric and piezomagnetic.

II. COMPUTATIONAL METHOD

Density functional theory calculations were performed using the Vienna Ab Initio Simulation Package (VASP) code in the projector augmented-wave method^{47–50}.

The DFT+U scheme of Dudarev *et al.*⁵¹ was employed to better describe strongly correlated $3d$ electron systems, as pure DFT with GGA functionals erroneously predicts a metallic band structure in CuFeS_2 . An effective energy penalty $U_{\text{eff}} = 4.7$ eV was applied to Fe $3d$ and $U_{\text{eff}} = 0.1$ eV to Cu $3d$. The Perdew-Burke-Ernzerhof functional for solids (PBEsol)⁵²

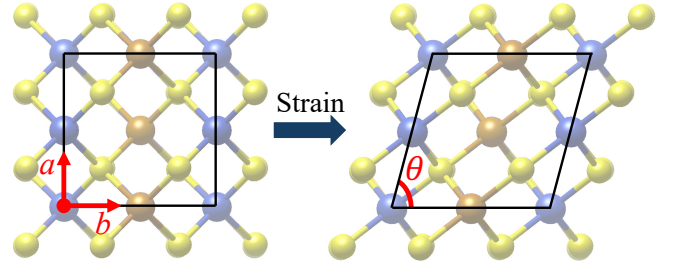


FIG. 2. Schematic illustrating the application of shear strain to the tetragonal bulk structure. Strain is applied distorting the ab plane, with the angle θ indicating the degree of shear strain.

was used from the GGA class, with the $3s^23p^4$, $3p^64s^13d^{10}$ and $3p^64s^13d^7$ states defined as valence states for S, Cu, and Fe, respectively.

The model builds on authors' previous work³⁰, which further elaborates on the choice of parameter values.

The four-formula unit conventional cell of CuFeS_2 found in Materials Project⁵³ entry MP-3497 represents its tetragonal bulk structure. A supercell consisting of $2 \times 2 \times 1$ conventional cells was built for computing the dielectric and magnetic properties. Spin-orbit interactions were accounted for in order to probe for a relativistic net magnetization. The Monkhorst-Pack scheme⁵⁴ with a Γ -centered $8 \times 8 \times 4$ k -point mesh was found suitable with the conventional cell. For the $2 \times 2 \times 1$ supercell, a proportionally-sized $4 \times 4 \times 4$ grid was meshed. The energy cut-off for the plane-wave basis is set at 700 eV to account for the magnetic interactions of iron's $3d$ orbitals. The inter-ionic forces were relaxed below $|10^{-5}|$ eV/Å and the electronic structure optimized such that the final convergence step was smaller than 10^{-8} eV for the system.

Biquadratic strain was applied biaxially to the planes spanned by the a and b , and a and c lattice vectors. The ac and bc planes are equivalent by rotation, which allows omitting the results for the bc plane. In this study, strain levels between -5% and 5% were explored in percentwise increments – silicon as substrate for CuFeS_2 thin film growth places inside this interval, exerting a tensile strain of about 3%, assuming a fully strained thin film.

The structure then relaxes along the out-of-plane lattice vector. In the case of biaxial strain, the Cartesian x , y and z axes coincide with the a , b and c lattice vectors, respectively.

Shear strain was applied as shown in Figure 2, in-plane with each of the three surface planes of the tetragonal crystal – ab , ac , and bc . As in the case of biaxial strain above, the ac and bc planes are equivalent due to rotational symmetry, producing identical responses under shear strain. The results will therefore be presented only for the ab and ac planes. As seen from Figure 2, decreasing the in-plane angle θ changes the in-plane lattice constants, effectively imposing compressive strain on the distorted plane. Thus, θ , the angle between the lattice vectors in the plane being distorted, is taken as a measure of the magnitude of shear strain applied.

The dielectric polarization values were obtained by per-

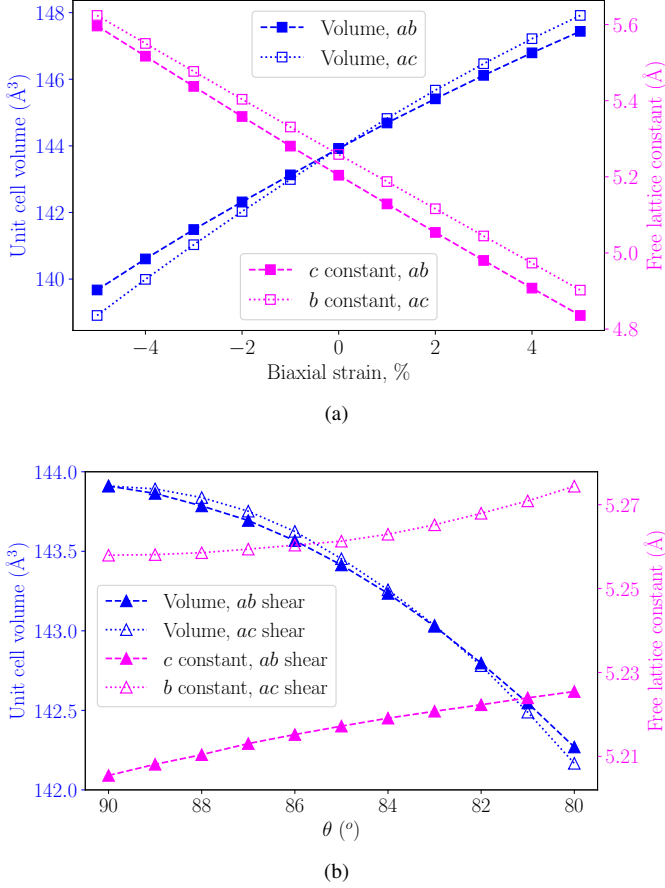


FIG. 3. Unit cell volume and magnitude of the out-of-plane (free) lattice parameter versus (a) biquadratic strain acting in-plane on the ab (solid square markers) and ac (hollow square markers) planes, and (b) shear strain, expressed by in-plane shear angle θ , acting on the same planes – hollow and solid triangle markers.

forming Berry phase^{55,56} calculations, as implemented in VASP. The angle θ was adopted as order parameter.

III. STRUCTURAL PHASE TRANSITIONS

Applying biquadratic strain in the ab plane preserves the tetragonal $I\bar{4}2d$ crystal symmetry. Biquadratic strain in the ac plane produces an orthorhombic $I2_12_12_1$ phase. Figure 3a shows the change in structural parameters under biaxial strain, indicating the change in cell volume and the free lattice constant when each of the crystal planes is distorted. For both non-equivalent planes, ab and ac , is the cell volume monotonically increasing when traversing all considered strain levels, from compressive to tensile.

Shear strain applied to the ab plane distorts the structure into an orthorhombic phase, $Fdd2$. Applying shear strain to the ac plane, the tetragonal structure is distorted into a monoclinic phase, space group $C2$. Decreasing the angle θ from an initial 90° , Figure 3b shows shear strain decreasing the volume of the unit cell via a compressive effect on the in-plane area noted in Section II, despite the expanding out-of-plane

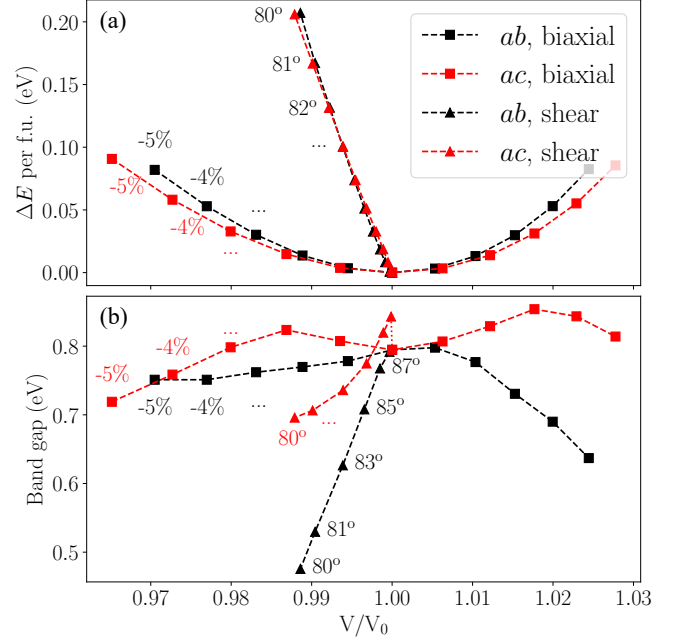


FIG. 4. (a) Energy curves of the phases emerging under biaxial (squares) and shear (triangles) strain relative to the relaxed tetragonal ground-state, represented by relative cell volume $V/V_0 = 1.00$. The ticks on the biaxial strain curves represent 1% strain increments from -5% to 5%. On the shear strain curves, the ticks represent one-degree increments from 80° to 90° , with 90° corresponding to $V/V_0 = 1.00$. (b) The indirect band gap versus biaxial and shear strain. The marker legend corresponds to that in (a).

lattice constant.

The orthorhombic $I2_12_12_1$ phase emerging under biaxial ac strain is a maximal subgroup of $I\bar{4}2d$. Its point group, 222 , however, is not polar. The maximal polar subgroups of the tetragonal ground state space group $I\bar{4}2d$ are the orthorhombic $Fdd2$ and monoclinic $C2$ space groups, achieved by ab and ac shear strain, respectively.

Figure 4a compares the differences in energy between the relaxed tetragonal ground state and the structures under biaxial and shear strain. The energy cost of shear strain is clearly higher than that of biaxial strain. Compressing the cell volume by 1% under shear strain costs an order of magnitude more energy than applying biaxial compressive strain.

A consequence of applying strain on the crystal structure is a change in the electronic structure, where the change in the indirect band gap from its computed ground state value of 0.795 eV is clearly observed. As seen from Figure 4b, shear strain demonstrates the largest decrease in band gap per decrease in cell volume. However, only when straining the ab plane is the bandgap almost monotonically decreasing under both compressive and tensile biaxial strain, as well as under the compressive effect of shear strain. For the ac plane, there is a decrease in band gap at higher strain levels, but the initial effect at shear angles above 85° and absolute biaxial strain levels below 2-3% is an increase in band gap by up to ~ 50 meV, about 6%.

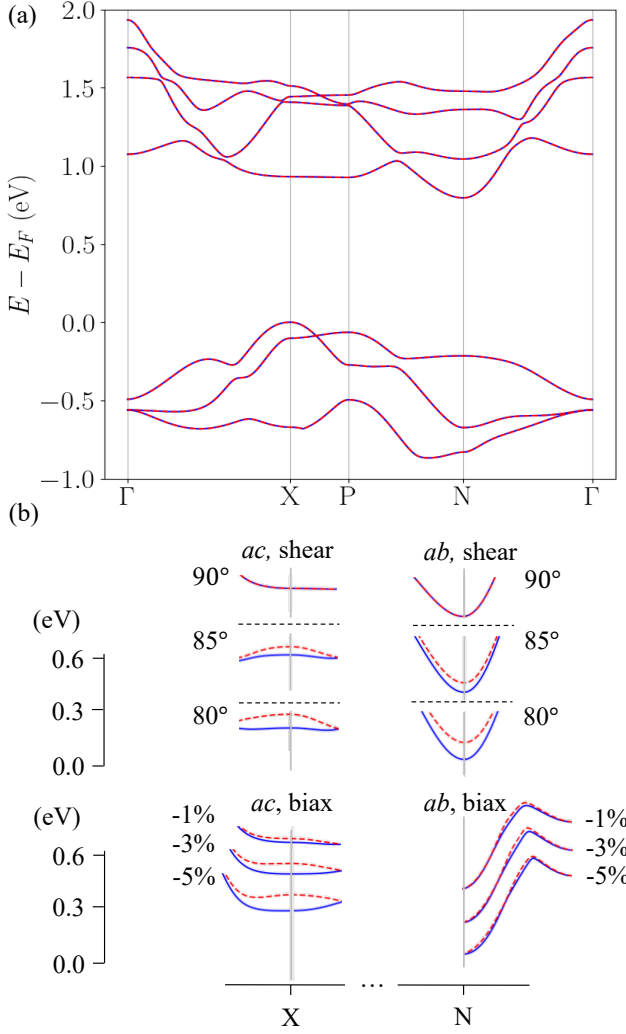


FIG. 5. (a) The non-relativistic band structure of bulk tetragonal CuFeS_2 showing degenerate spin bands. (b) Lifting of degeneracies in the two lowest spin-up and -down conduction bands, represented by the dashed red and solid blue curves, induced by shear and biaxial strain. The degenerate ground state is included at 90° . Strain applied to the ab plane induces band splits at or around the N point, while strain applied to the ac plane splits the bands at the X point and around it. The energy scales in (b) illustrate the magnitude of the band splittings, not the energy from Fermi level.

Figure 5a presents a band structure of the relaxed tetragonal crystal simulated without spin-orbit interactions, showing degenerate spin channel bands. A lifting of spin band degeneracies in the conduction and valence bands is expected when spin-orbit coupling (SOC) is accounted for^{4,14} and was demonstrated in CuFeS_2 ³⁰. SOC interactions are not strong in this compound, inducing a splitting in the spin bands near Fermi level on the order of a few meV. However, unlike the case of conventional collinear antiferromagnets, the lifting of Kramer's degeneracy in altermagnets is not due to e.g. relativistic spin-orbit interactions in a structure with bro-

ken inversion symmetry. Altermagnets have a joint time reversal and inversion symmetry broken. Thus, the altermagnetic spin band splittings have been demonstrated without SOC^{31,32,34,57,58}. Moreover, unlike non-degenerate bands in ferromagnets, the altermagnetic band splitting does not require a net magnetization.

Figure 5b presents line segments along the lowest pair of spin-up and -down conduction bands from non-relativistic band structures under biaxial and shear strain, applied to the two non-equivalent crystal planes, ab and ac . The figure shows that strain lifts the spin band degeneracies at the X and N points, and the low-symmetry line segments around them, depending on which plane it is applied to. Applying either biaxial or shear strain to the ac plane mainly splits the bands at the X point, while applying it to the ab plane splits the bands at the N point. Higher levels of strain produce larger gaps between the spin channels, as the ground state symmetry is distorted to a higher degree. Notably, biaxial strain applied to the ab plane induces clearly discernable splits around the N point, although it does not break any symmetries.

Figure 5b shows only compressive biaxial strain for comparison with the compressive effect of shear strain. However, the splittings are of a similar magnitude under tensile biaxial strain. Applying strain to the ac plane yields the highest splits, on the order of 0.1 eV, under the highest levels of biaxial and shear strain considered here. In currently researched altermagnets, such as MnTe , ReO_2 , CrSb or V_2SeTeO , these band splittings can be on the order of 1 eV^{14,31,32,34}.

IV. MAGNETIC RESPONSE TO STRAIN

The magnetic symmetry class of CuFeS_2 allows for a piezomagnetic response. The piezomagnetic tensor relates applied strain to an induced magnetization and takes the form⁵⁹

$$\begin{pmatrix} 0 & 0 & 0 & -\Lambda_{14} & 0 & 0 \\ 0 & 0 & 0 & 0 & \Lambda_{14} & 0 \\ 0 & 0 & 0 & 0 & 0 & 0 \end{pmatrix} \quad (1)$$

with finite elements $\Lambda_{ij} > 0$.

The net induced magnetization per Fe ion is shown in Figure 6a. Shear strain applied to the ab plane yields no piezomagnetic response, though the lifting of band degeneracies under this mode of strain was observed in Figure 5. According to Eqn. (1), only shear strain applied to the ac or bc planes results in a non-zero piezomagnetic response normal to the distorted plane. Thus, Figure 6a shows ac shear strain induce an uncompensated non-zero magnetic moment m_y , perpendicular to the ac plane. The equally large magnetization m_x resulting from applying shear strain to the bc plane is omitted from the figure due to symmetry, as explained earlier. In the absence of shear strain, at $\theta = 90^\circ$, the net magnetic moment vanishes. This is consistent with CuFeS_2 being a fully compensated magnet in its ground state. The linear dependence of the piezomagnetic response on strain agrees with the tensor, Eqn. (1), only for small angle deviations from the tetragonal ground state. Figure 6a shows the response at a few degrees lower than 80° to demonstrate the emergence

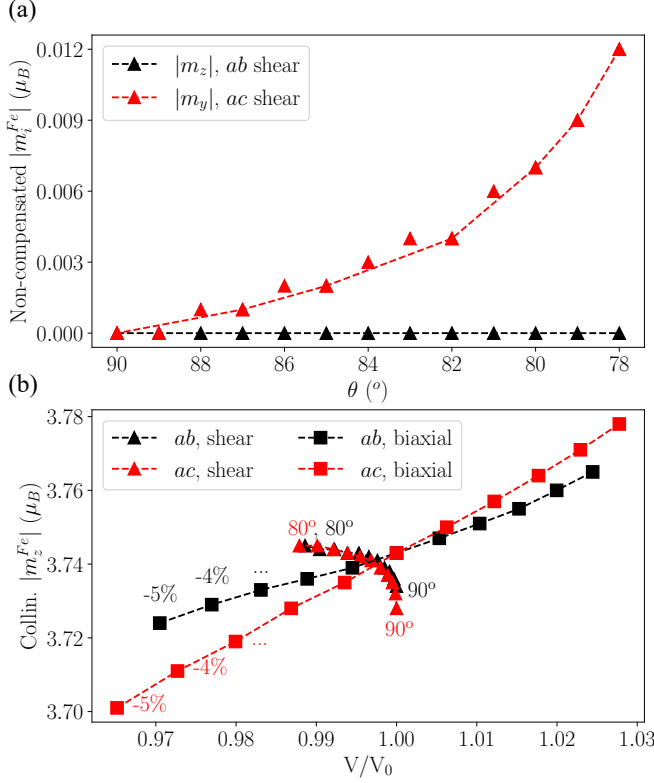


FIG. 6. (a) The non-compensated piezomagnetic response to shear strain per Fe ion, perpendicular to the distorted plane. The discontinuities in magnetic moments are due to a lower bound in numerical accuracy of $0.001 \mu_B$. (b) Collinearly compensated z component of magnetic moment per Fe ion under the full range of biaxial and shear strain levels considered.

of a higher-order dependence at larger shear angles. As the structure symmetry is lowered, the polarization axis will deviate from the y axis, with other spin vector components no longer fully compensated. However, the z component of Fe spin vectors, previously illustrated in Figure 1 is still fully compensated at the angles considered. Figure 6b shows the evolution of the z component magnitude under biaxial strain and shear distortion. The change in magnitude under biaxial strain is larger than under shear strain. There is also a fully compensated x spin component that emerges under ac shear, omitted in Figure 6. Equivalently, a fully compensated y component emerges under bc strain, increasing as θ decreases. Its magnitude at the angles considered is between 0.0 and $0.2\mu_B$ per Fe ion, imparting a slight cant to the spin structure under strain, as opposed to the spins being oriented strictly along the z axis in the ground state. The uncompensated piezomagnetic response to shear strain in Figure 6a also produces canting, but the effect is at least one order of magnitude smaller than the compensated in-plane component, such that the total spin structure is directed along the larger compensated spin components.

Biaxial strain does not induce a net magnetization, as both phases emerging under biaxial strain contain only shear elements in their piezomagnetic tensors. The magnitude of the

magnetic moments of Fe ions changes with the lattice parameters, but a fully compensated spin structure is maintained. The magnetic moment of each Fe ion is always parallel or antiparallel with the z axis, as in the ground state in Figure 1, with no other non-zero spin vector components.

V. PIEZOELECTRIC RESPONSE

CuFeS_2 is non-polar in its tetragonal ground state, point group $\bar{4}2m$. However, the absence of inversion symmetry in space group $I\bar{4}2d$ allows a finite piezoelectric response given by a piezoelectric tensor of the form

$$\begin{pmatrix} 0 & 0 & 0 & d_{14} & 0 & 0 \\ 0 & 0 & 0 & 0 & d_{14} & 0 \\ 0 & 0 & 0 & 0 & 0 & d_{36} \end{pmatrix}. \quad (2)$$

According to Neumann's principle, the piezoelectric tensor is consistent with the crystal symmetry^{59,60}. Eqn. (2) does not support a piezoelectric response without breaking the tetragonal ground state symmetry. The orthorhombic $I2_12_12_1$ phase produced by biaxially straining the ac plane, likewise, does not show a piezoelectric response, unless shear strain is applied. As in the case of the piezomagnetic tensor, Eqn. (1), polarization is induced perpendicularly to the plane distorted by the application of shear strain. A non-zero polarization is induced from distorting the ab plane, as well as that from the distortion of the ac and bc planes.

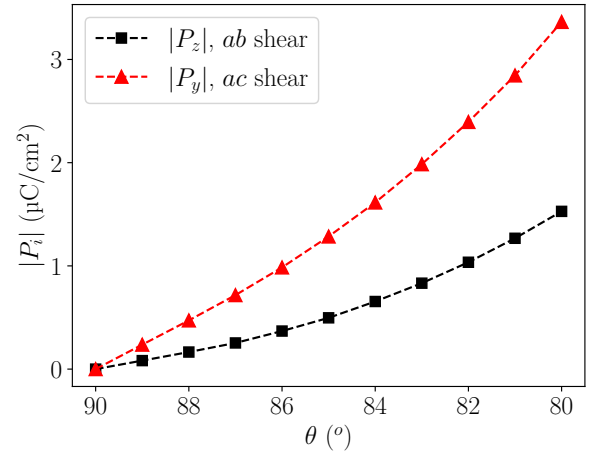


FIG. 7. Absolute values of the shear strain-induced out-of-plane polarization for each distorted plane.

Figure 7 plots the absolute values of the out-of-plane polarization induced by shear strain acting on the three distinct planes. The bc plane is again omitted due to it being equivalent to the ac plane. Notably, the response is linear for small-angle deviations from $\theta = 90^\circ$. As non-linear effects become apparent at angle $\theta = 89^\circ$ and lower, a linear response description by the tensor in Eqn. (2) becomes insufficient.

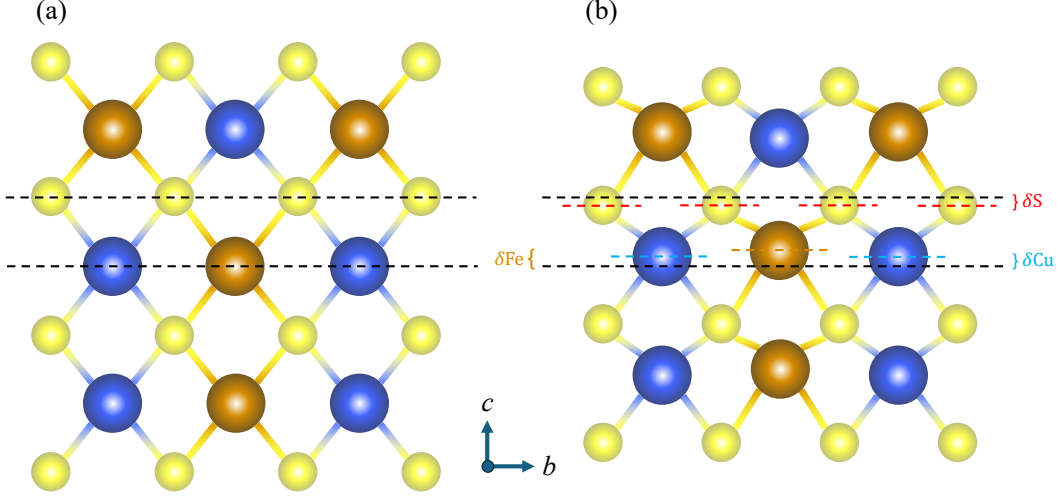


FIG. 8. (a) Relaxed CuFeS₂ crystal lattice with all cations and anions at their equilibrium positions. (b) Displacements in the ionic positions along the *c* lattice vector, relative to their equilibrium positions under a shear distortion of the crystallographic *ab* plane. The shift δ of each atomic type is marked with a dotted line of corresponding color. The shifts in the figure are exaggerated for illustrative purposes.

TABLE I. Fractional absolute coordinate shifts between each type of cation and the S anion along the polarization axis under in-plane strain, as expressed by shear angle θ . The displacements at $\theta = 90^\circ$ represent the case of applying biaxial strain, with the values of the out-of-plane lattice constant included for reference.

θ ($^\circ$)	Strain applied to the <i>ab</i> plane			Strain applied to the <i>ac</i> plane		
	$ \partial Cu_z - \partial S_z $	$ \partial Fe_z - \partial S_z $	<i>c</i> (Å)	$ \partial Cu_y - \partial S_y $	$ \partial Fe_y - \partial S_y $	<i>b</i> (Å)
90	0	0	5.2055	0	0	5.2580
89	0.0018	0.0021	5.2081	0.0040	0.0041	5.2581
88	0.0036	0.0042	5.2104	0.0080	0.0081	5.2585
87	0.0054	0.0063	5.2131	0.0120	0.0123	5.2594
86	0.0072	0.0084	5.2152	0.0159	0.0164	5.2604
85	0.0090	0.0103	5.2172	0.0202	0.0205	5.2613

As θ decreases from 90° , the polarization magnitude follows piezoelectric tensors corresponding to the orthorhombic and monoclinic phases produced by shear distortions. These tensors exhibit a non-zero response both from shearing and non-shearing strain simultaneously, producing the higher-order relation seen in Figure 7.

Focusing on small angles, where the response is linear and uniaxial, the mechanism of piezoelectric response in the *ab* and *ac* shear strain is similar, though the polarization magnitude differs. Using the *ab* plane for illustration, distorting this plane exerts compressive in-plane strain, prompting the *c* lattice constant to expand. The expansion results in opposite ionic movements along the *c* lattice vector on the polarization axis. The Cu and Fe cations shift upwards in the unit cell, while the S anions shift downwards. An exaggerated illustration of this is sketched in Figure 8.

Table I tabulates the pairwise shift between each cation and S relative to their initial site coordinates in the unit cell. The coordinates are expressed in fractions of the lattice constant along the polarization axis. Under *ab* strain, copper and iron ions move in the positive *z* direction, while S ions move in the opposite direction. The pairwise displacements are shown as

absolute values. At 90° , the displacement values correspond to the case of biaxial strain, with the ground state lattice constant included for reference. Under biaxial strain, the ions move proportionally with the expanding lattice constant and their site coordinates do not change. The shifts between the cations and anions compensate one another, such that the in-plane centrosymmetry shown in Figure 8a is preserved. Under shear strain, the ions shift disproportionately with the lattice constant, as shown in Figure 8b. This breaks the centrosymmetry along the polarization axis and gives rise to a dipole moment. Initially, the pairwise cation-anion displacements are along the polarization axis, normal to the distorted plane. Table I shows that these displacements are nearly constant per degree shear angle. At shear angles of 85 degrees and lower, in-plane shifts of S anions become similar in magnitude to the out-of-plane component, giving rise to the non-linearity seen in Figure 7. A similar polarization mechanism is observed under shear strain applied to the *ac* plane, producing a piezoelectric response in the *y* direction. The ionic displacements are in this case about twice as large in magnitude, relative to the dimension along the polarization axis, as compared to the case of applying shear strain to the *ab* plane.

VI. CONCLUSION

The magnetic symmetry class of CuFeS_2 makes it an altermagnet. While the non-relativistic band structure does not exhibit non-degenerate bands, the lifting of band degeneracies can be observed even without breaking the ground state symmetry with the application of biaxial and shear strain. Notably, shear strain produces polar structural transitions that induce electric polarization and net magnetization. Applying shear strain to each of the ab , ac and bc planes produces electric polarization normal to the planes. Shear strain applied to the ac and bc planes induces an uncompensated magnetic moment that gives rise to a net spin polarized magnetic structure. Thus, depending on the plane the strain is applied to, CuFeS_2 exhibits either a piezoelectric response or a simultaneous piezoelectric and piezomagnetic response.

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DATA AVAILABILITY STATEMENT

The data that support the findings of this study are available from the corresponding author upon reasonable request.

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